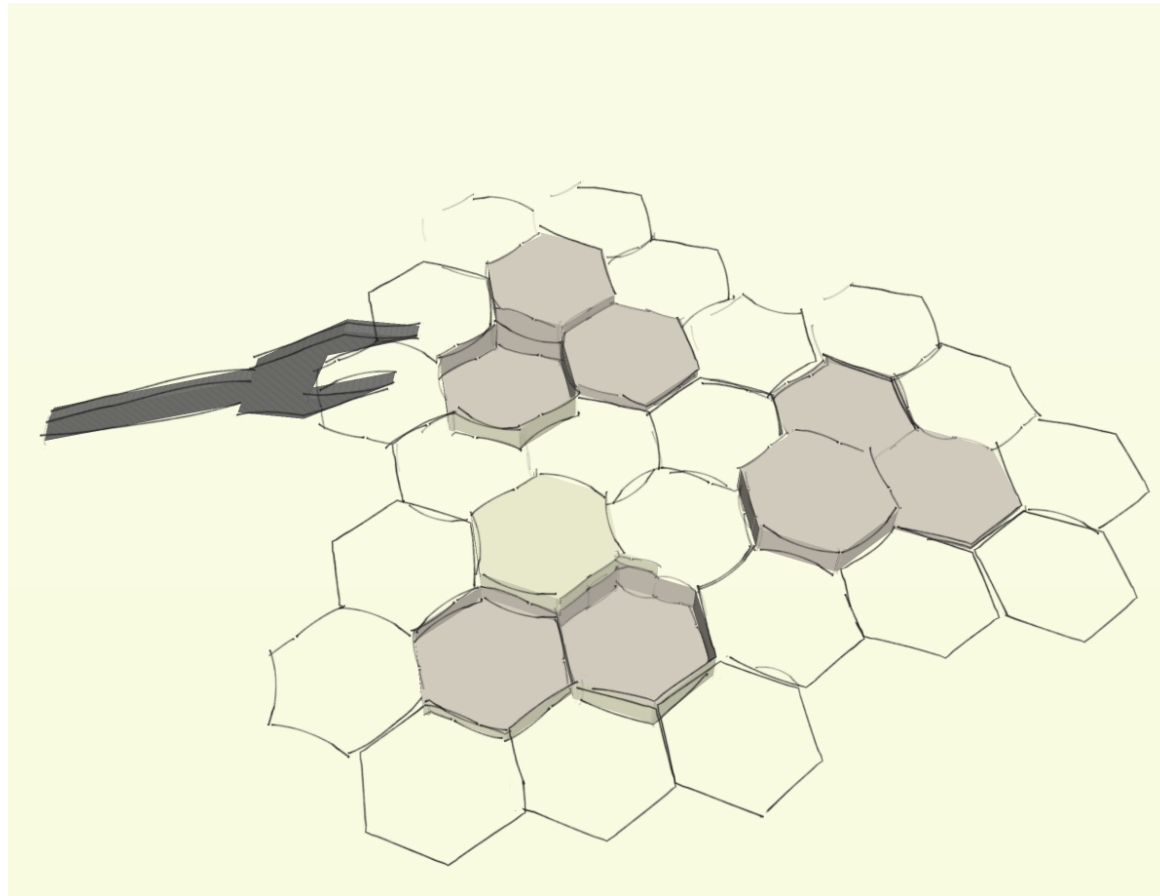


Modification of Graphene Films by Laser-Generated High Energy Particles



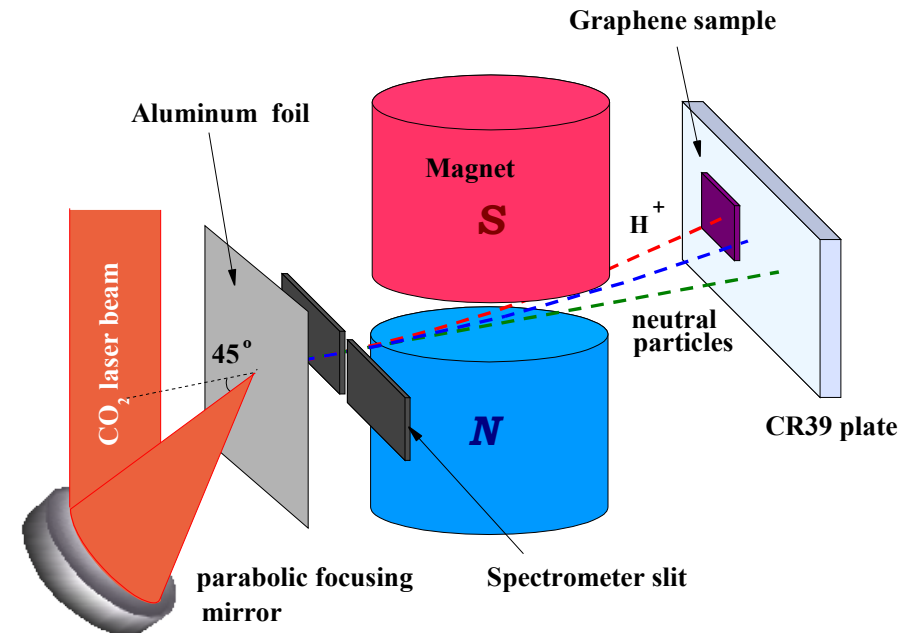
Elena Stolyarova (Polyakova), Ph.D.

ATF Program Advisory and ATF Users' Meeting
April 2-3, 2009, Berkner Hall, Room B, BNL

Modification of Graphene Films by Laser-Generated High Energy Particles

- The world of sp^2 carbon
- What is graphene?
- Graphene: the thinnest impermeable membrane

- High energy particles and nanotechnology
- Possible applications and future plans



Observation of Graphene Bubbles and Effective Mass Transport under Graphene Films

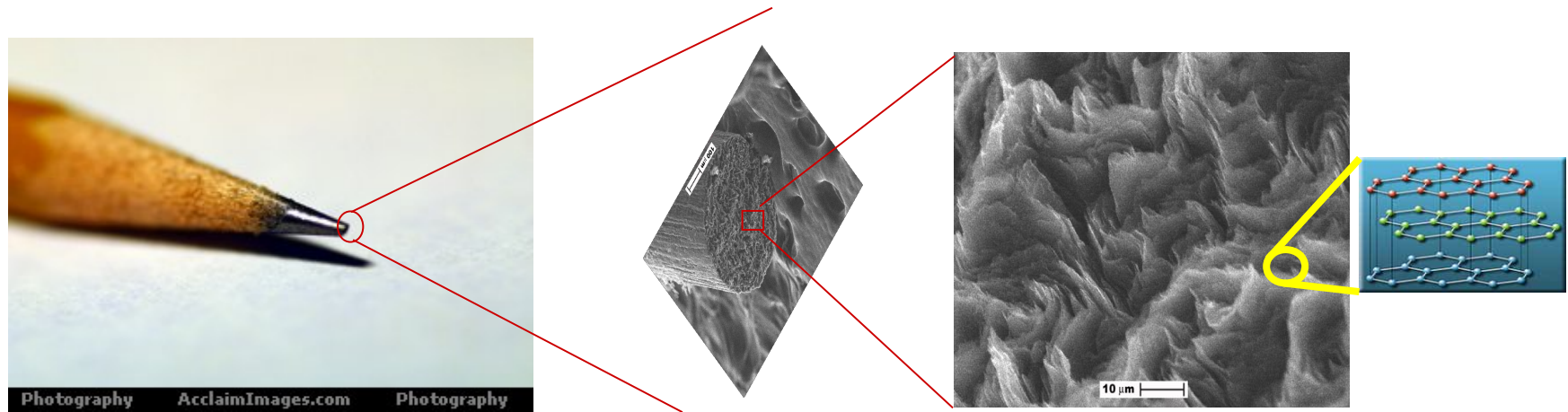
E. Stolyarova, D. Stolyarov, K. Bolotin, S. Ryu, L. Liu, K. T. Rim, M. Klima, M. Hybertsen, I. Pogorelsky, I. Pavlishin, K. Kutsche, J. Hone, P. Kim, H. L. Stormer, V. Yakimenko, and G. Flynn

Nano Lett., 2009, 9 (1), 332-337 • DOI: 10.1021/nl803087x • Publication Date (Web): 23 December 2008

Carbon: remarkable element

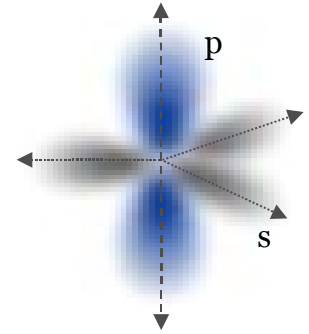


Carbon: remarkable element



SP₂ Carbon: 0-D to 3-D

Atomic orbital sp₂



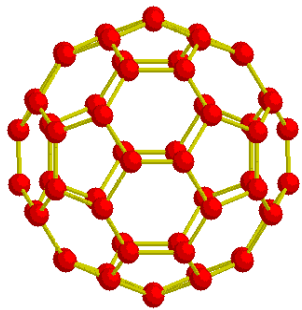
0D

1D

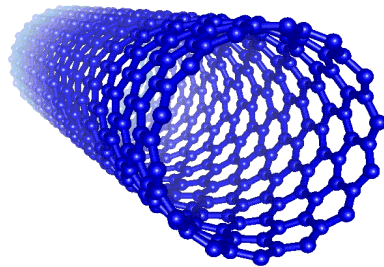
2D

3D

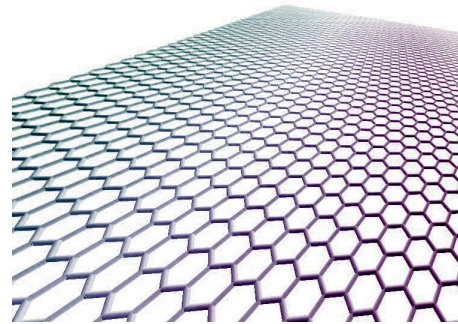
Fullerenes



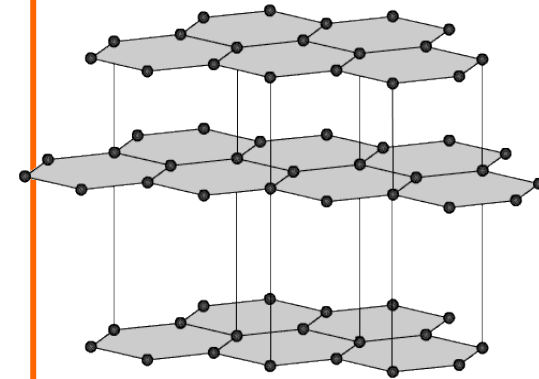
Carbon Nanotubes



Graphene

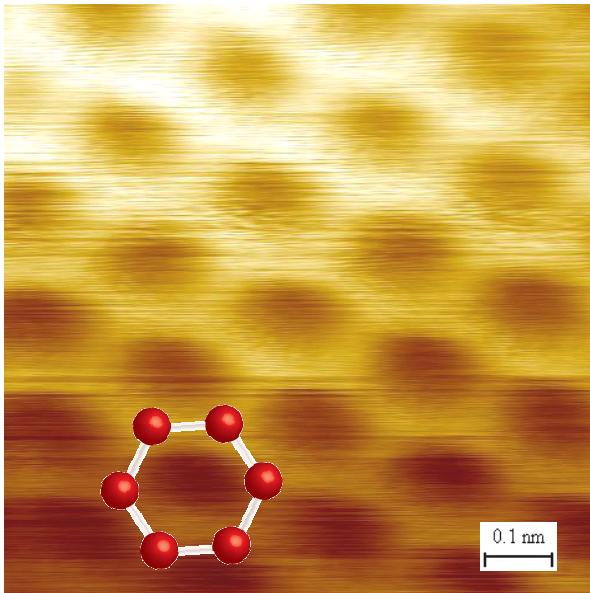
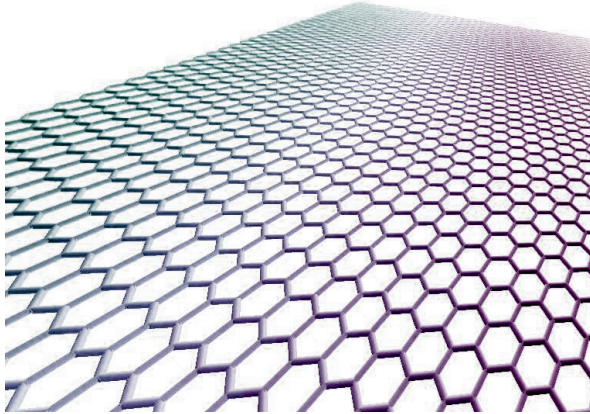


Graphite

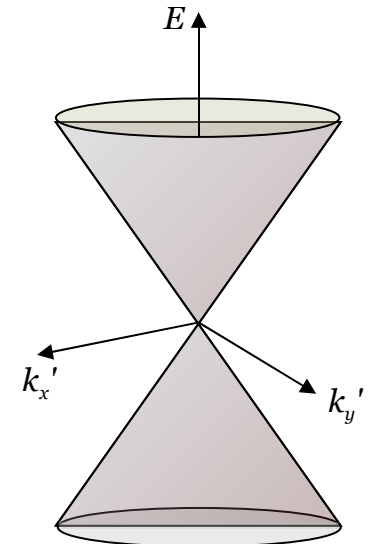


Graphene: a novel exciting material

- One atom thick crystal
- Conductive (High Mobility)
- Unusual electronic properties
- Stable, chemically inert
- Stiff
- Gas-impermeable

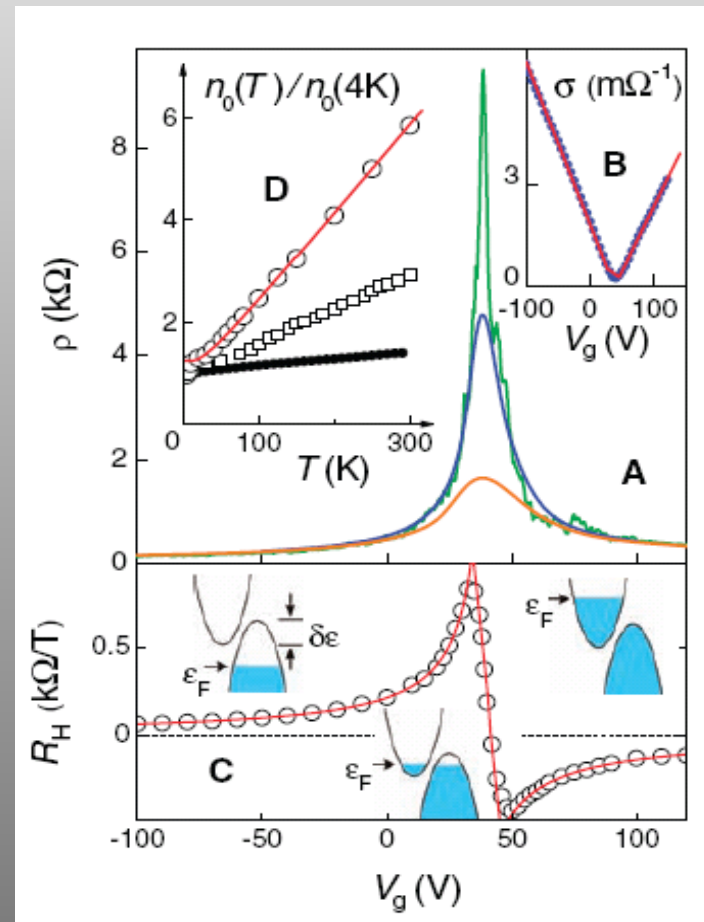
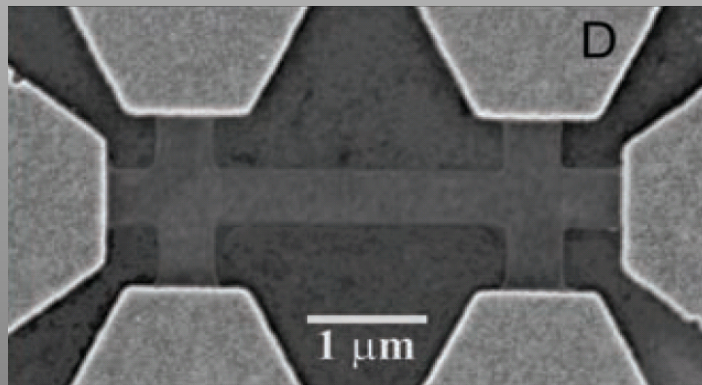
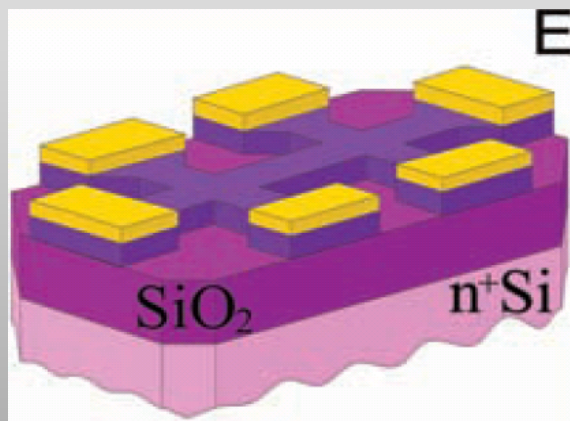


STM image of graphene



Electric Field Effect in Atomically Thin Carbon Films

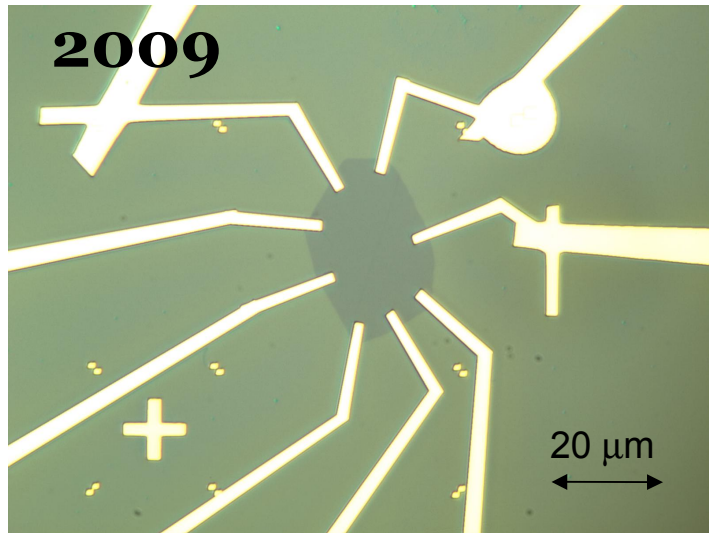
K. S. Novoselov,¹ A. K. Geim,^{1*} S. V. Morozov,² D. Jiang,¹
Y. Zhang,¹ S. V. Dubonos,² I. V. Grigorieva,¹ A. A. Firsov²



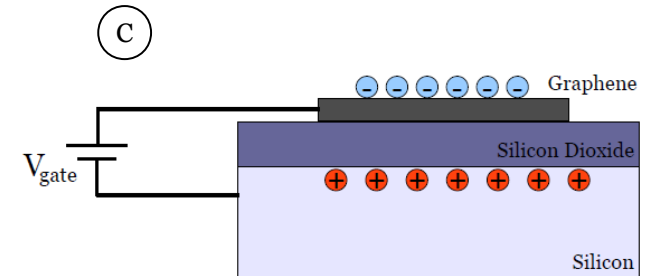
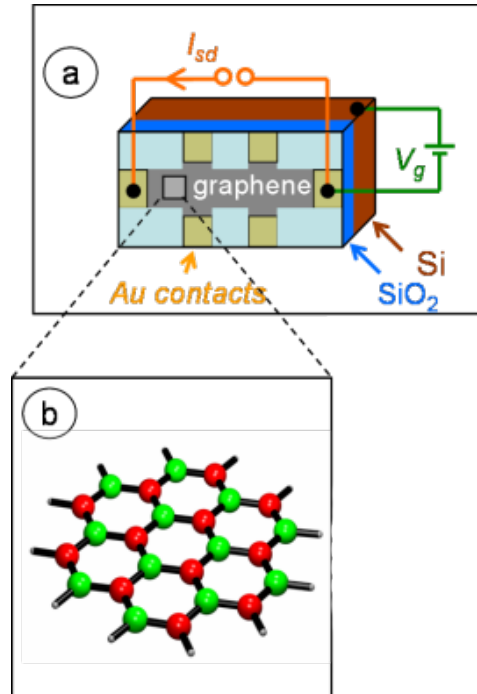
Graphene Field-Effect Transistors



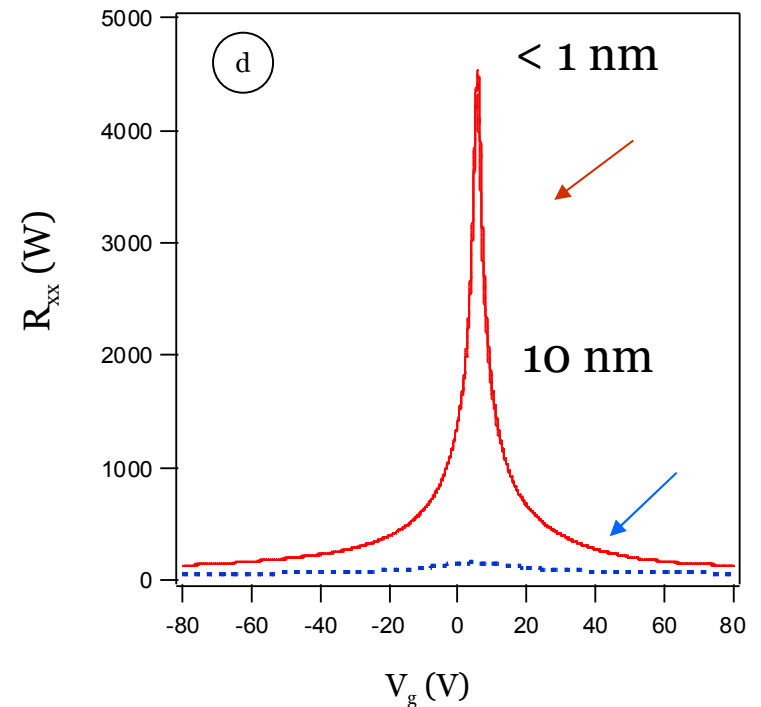
A replica of the first transistor



Single layer graphene device



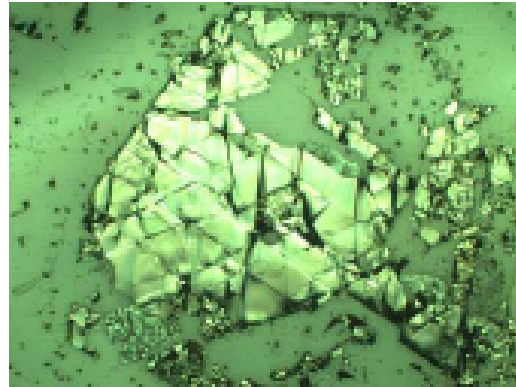
Resistance vs Gate Voltage



Mechanical Exfoliation of Graphene



Graphite Flakes (Kish, Toshiba Ceramics)



Graphite Flake



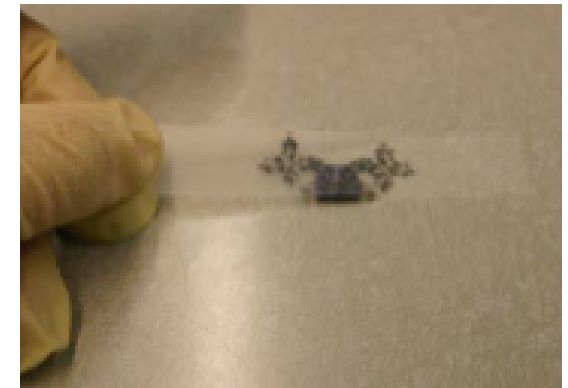
Peeling a Graphite Flake



Cleaving to a SiO_2/Si wafer

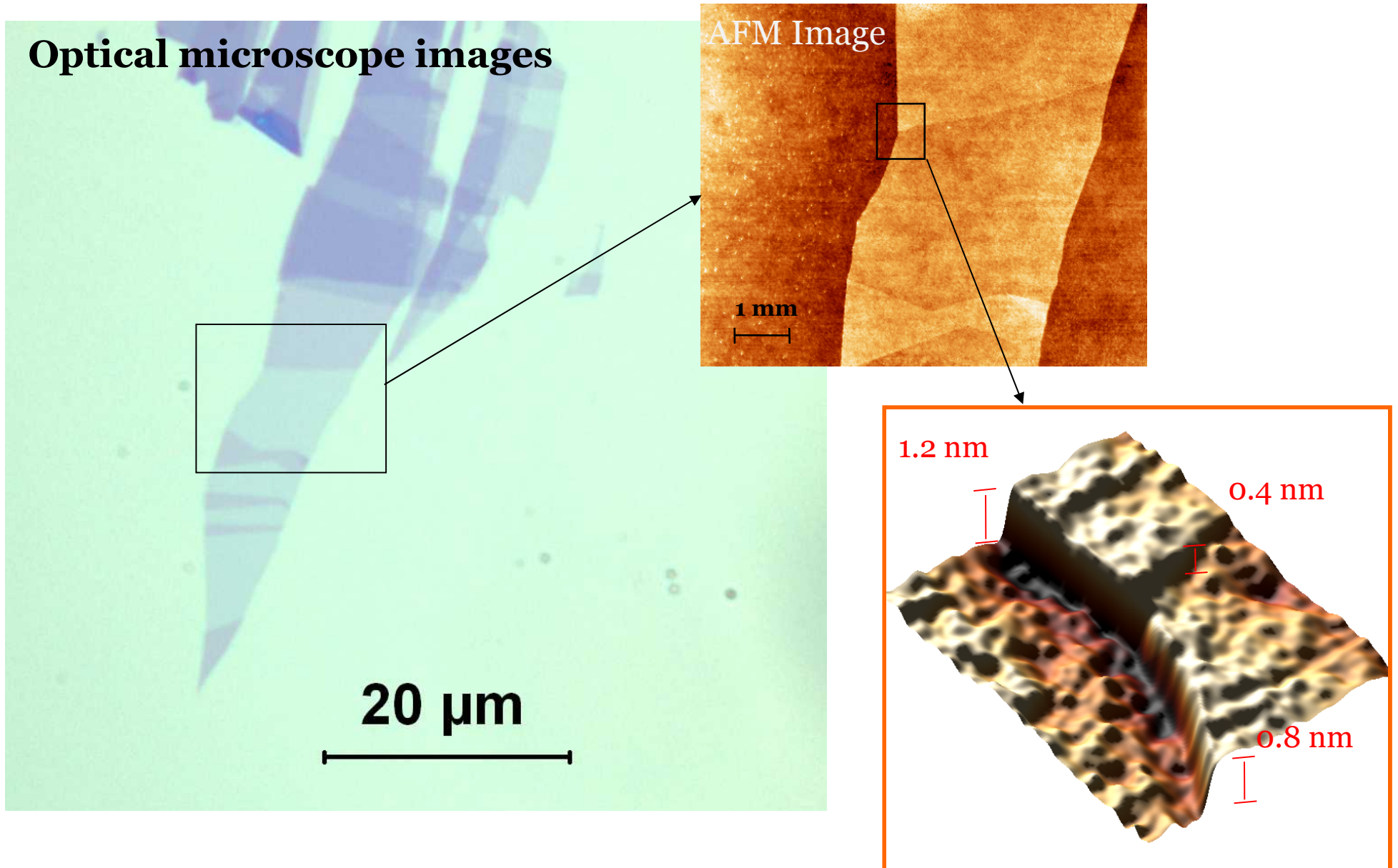


Gentle Rubbing with plastic Tweezers

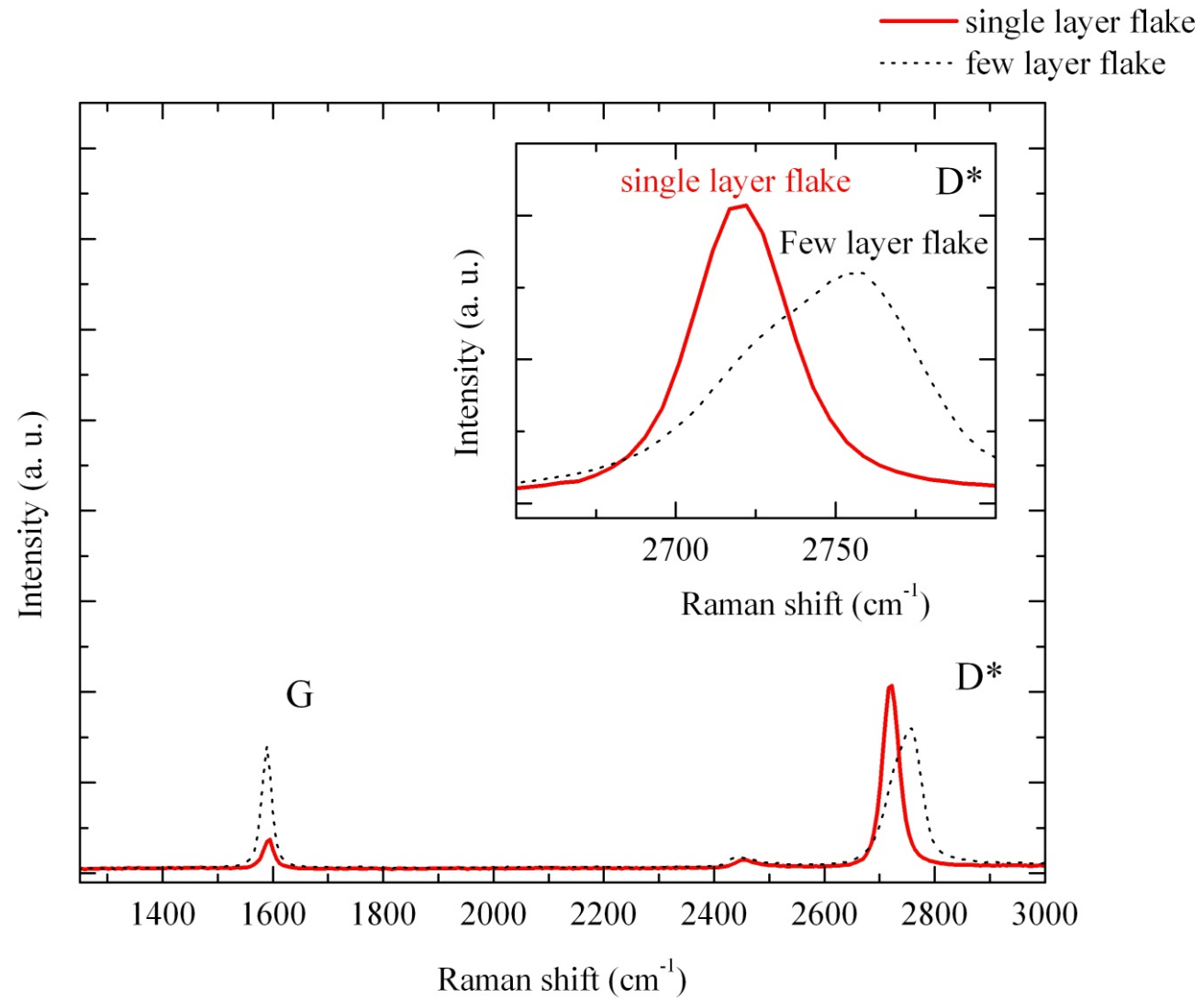


Removing the Scotch Tape

A Few Layer Graphene on SiO₂/Si Substrate



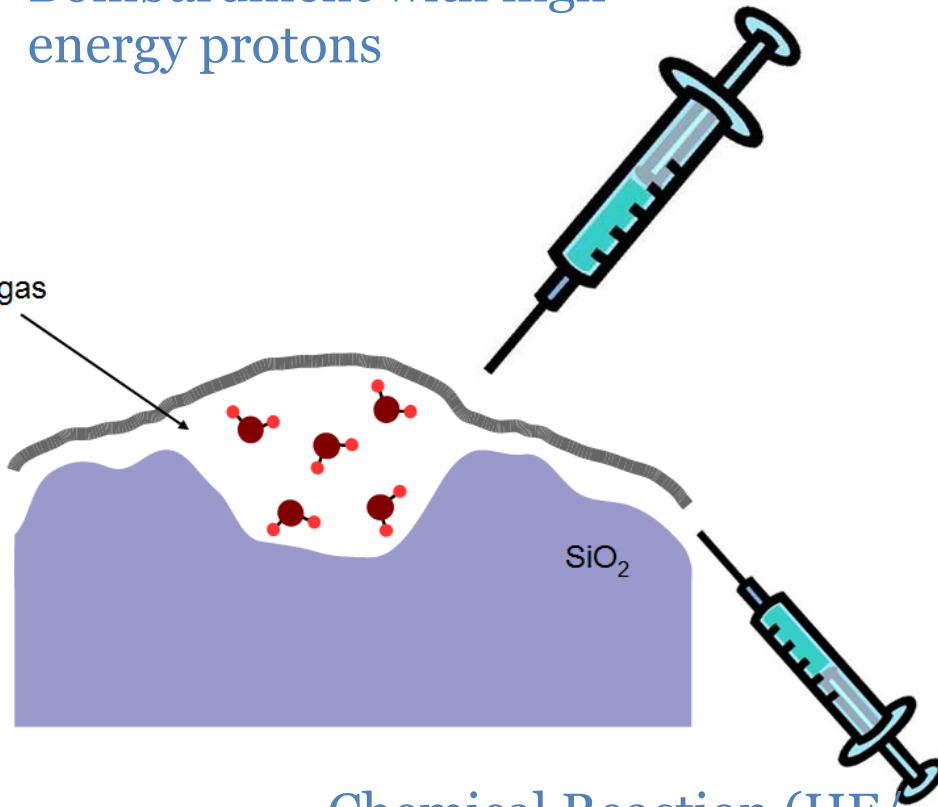
Raman Spectroscopy is a reliable tool for single layer identification



Observation of graphene bubbles and effective mass transport under graphene films

Bombardment with high energy protons

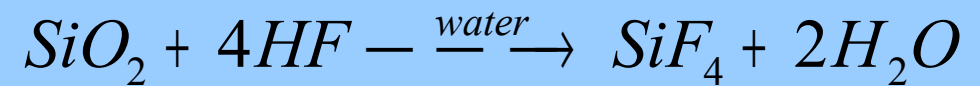
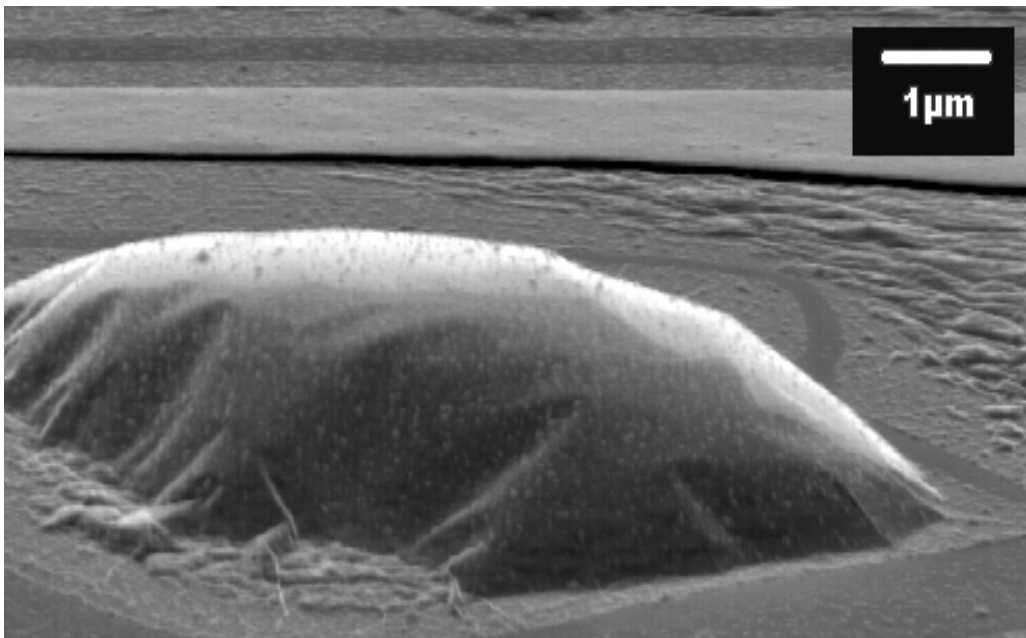
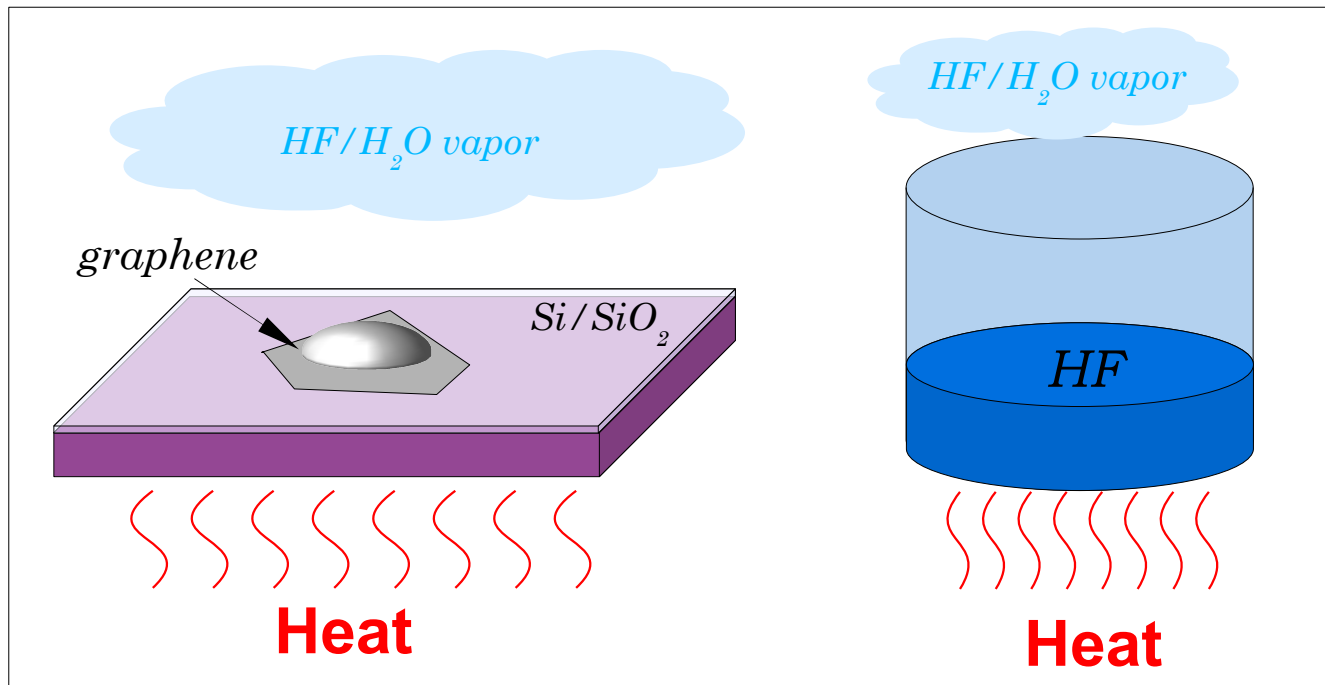
Isolated gas



Chemical Reaction (HF/
H₂O etching)

- Can we insert molecules under the graphene film?
- Can a molecule penetrate through a graphene?
- Do molecules move across graphene-silicon dioxide interface?

“Chemical” method for making bubbles

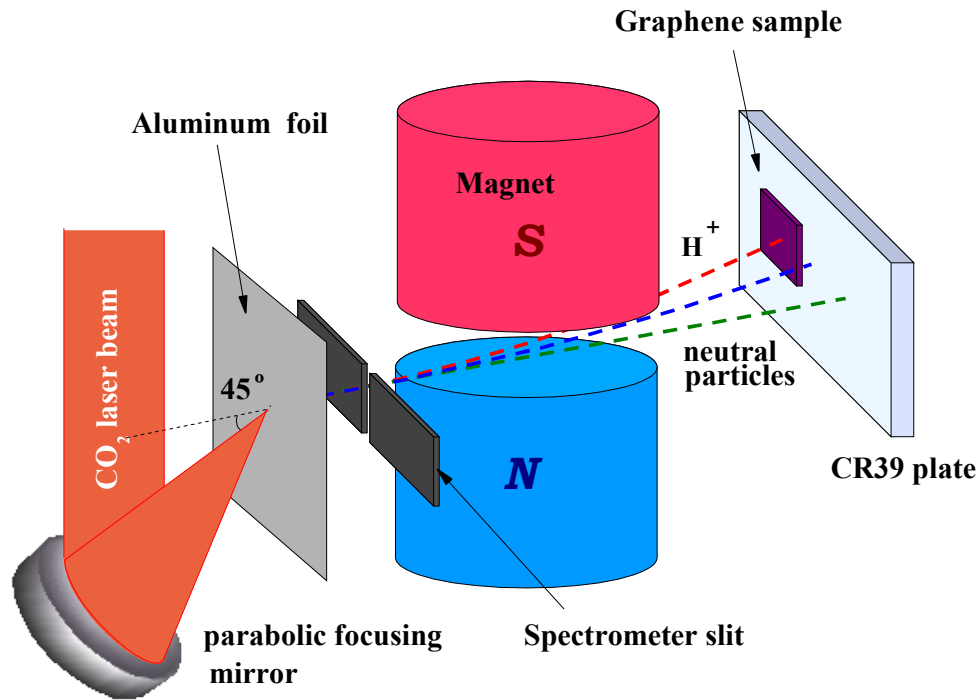


Huge graphene bubbles

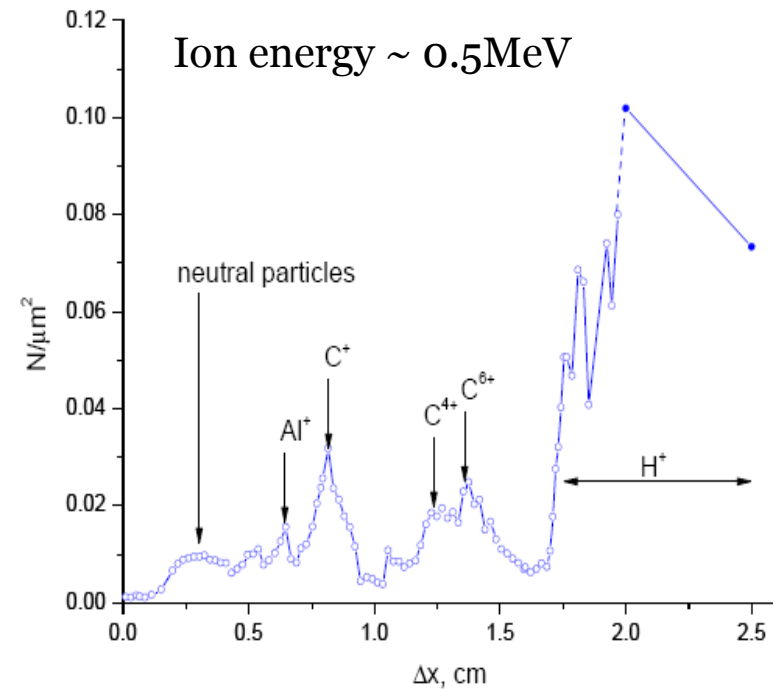
- Stable for months
- Raman spectrum is similar to supported graphene
- Can be destroyed by AFM tip
- Formed only if SiO₂ is etched completely

Proton Irradiation of Graphene Flakes

ATF TNSA Source



CR39 track density vs deflection distance

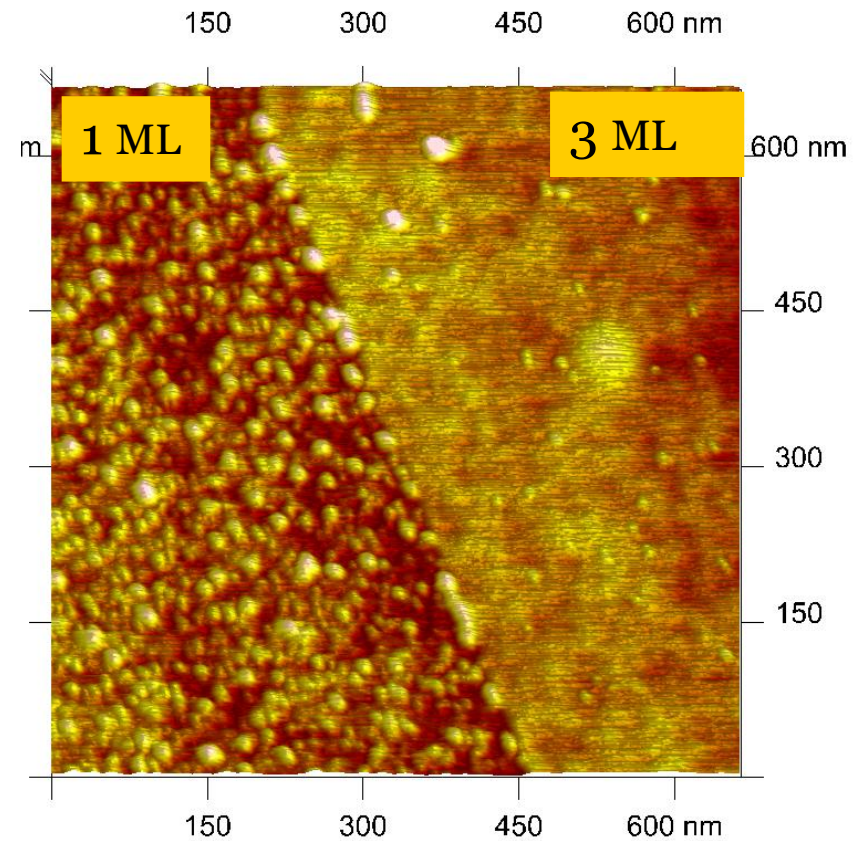
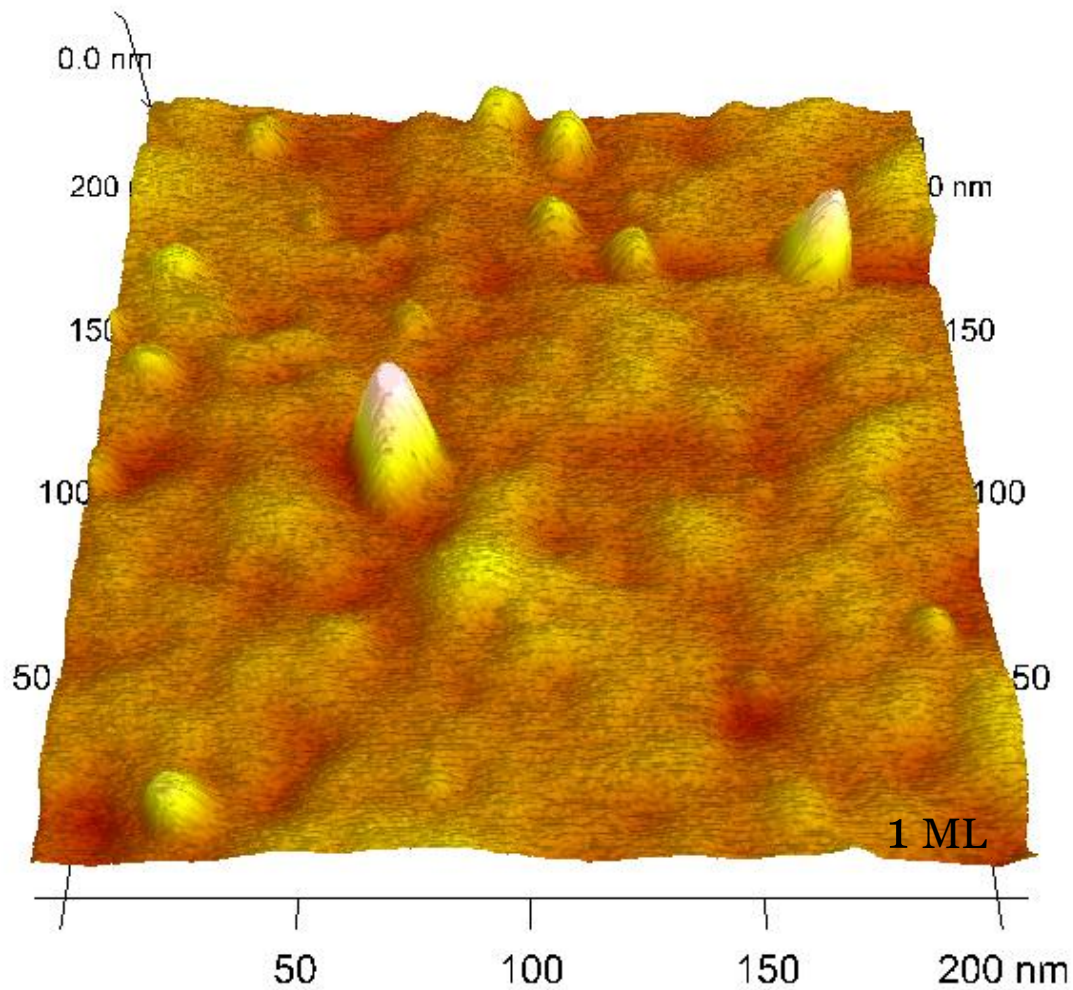


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Accelerator Test Facility

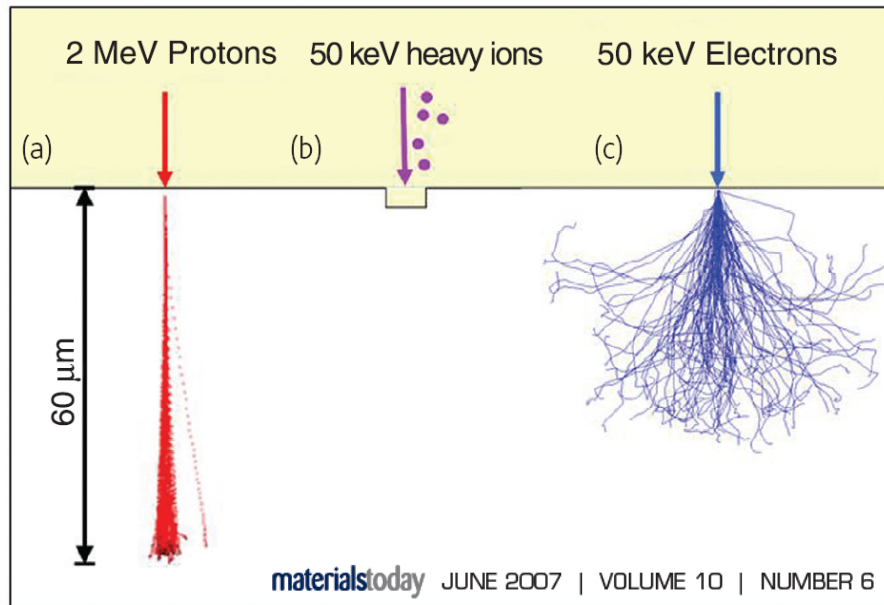


AFM Images of irradiated graphene samples: Nanoscale bubbles



- Small gas bubbles are formed
- Gas molecules are trapped between graphene and SiO_2

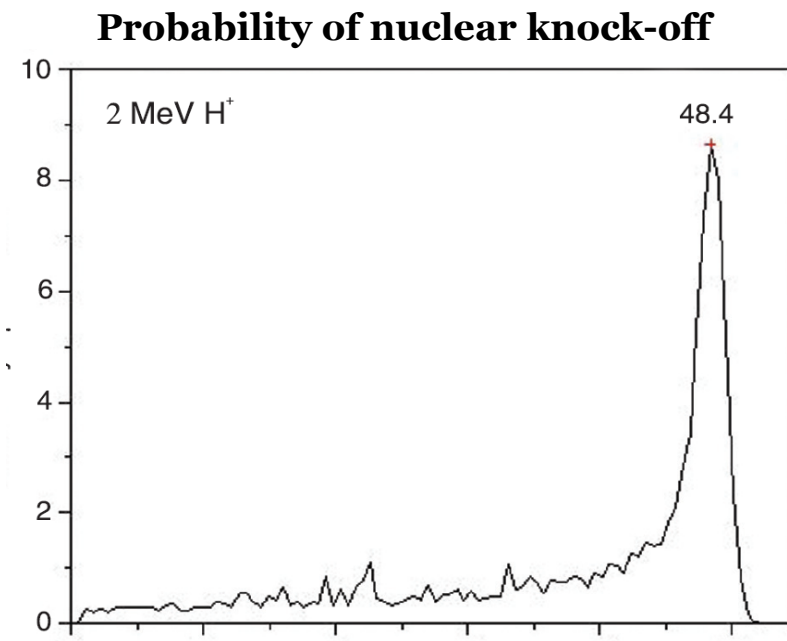
Propagation of a proton through the solid target



- Protons are only weakly deviated from the straight path
- Nuclear knock-off damage is significant only in the end of the track
- Energy loss per distance traveled is nearly uniform

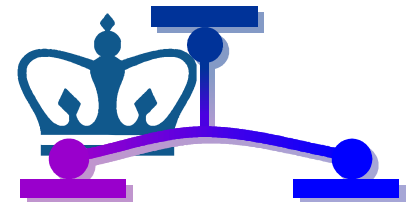
Applications of proton beams

- Cancer therapy
- 3D lithography
- Magnetic carbon

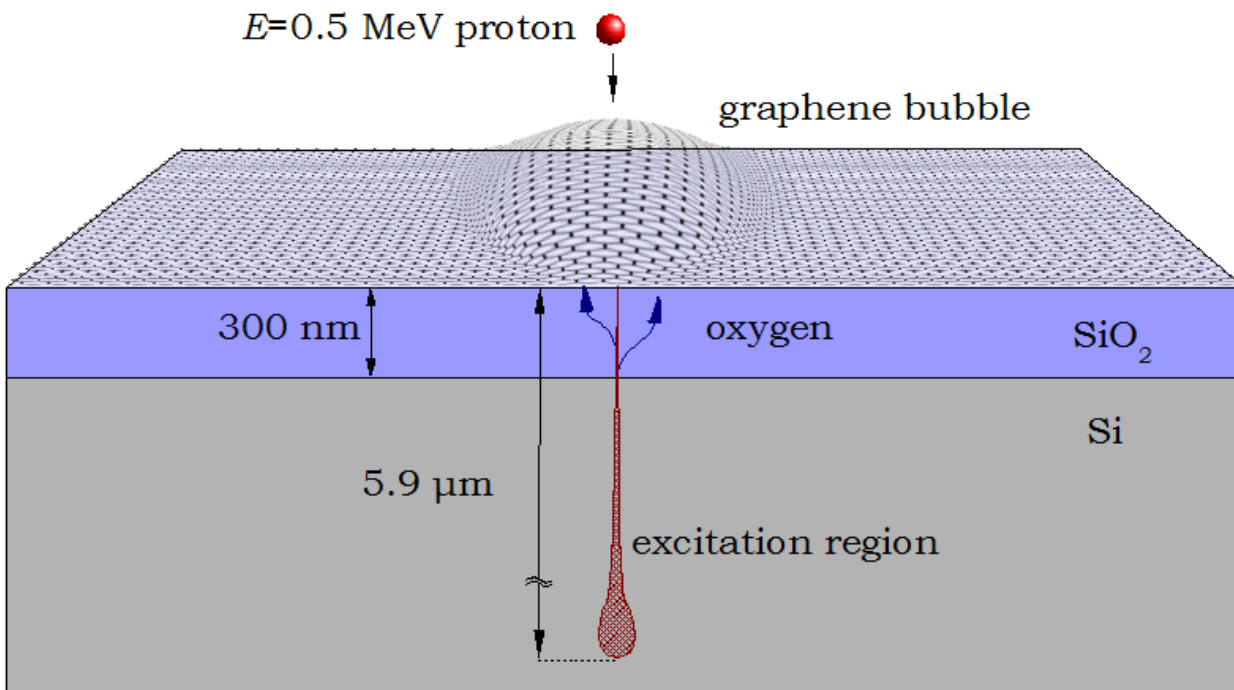


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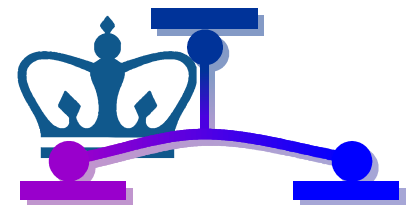
Accelerator Test Facility



Propagation of a proton through the graphene sample



- Probability of the defect formation in graphene is extremely low
- 99.9% of proton's kinetic energy is deposited in electronic excitations
- The 0.5 MeV protons stops deep inside the Si wafer
- Gas is expected to be released from the substrate
- Irradiation causes desorption / rearrangement of surface impurities



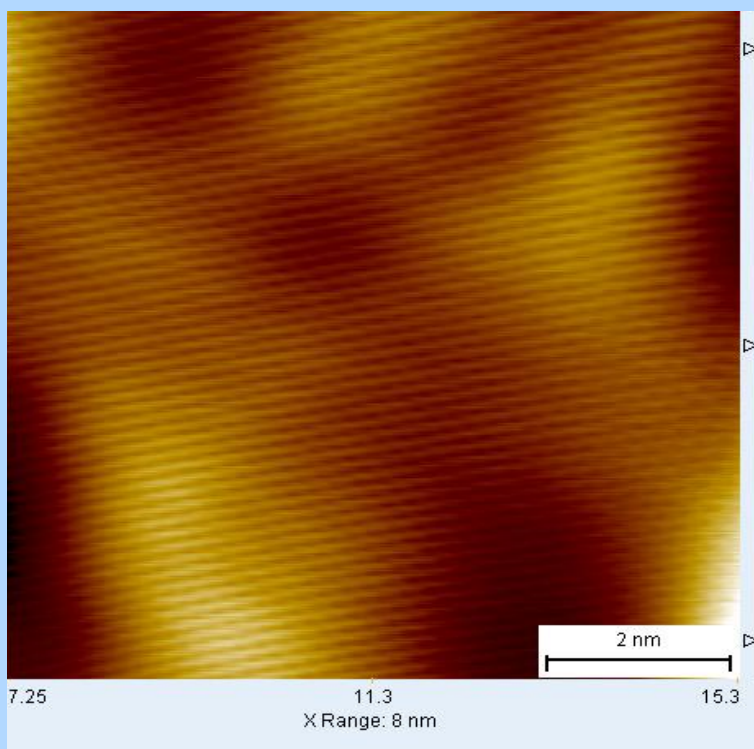
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Accelerator Test Facility



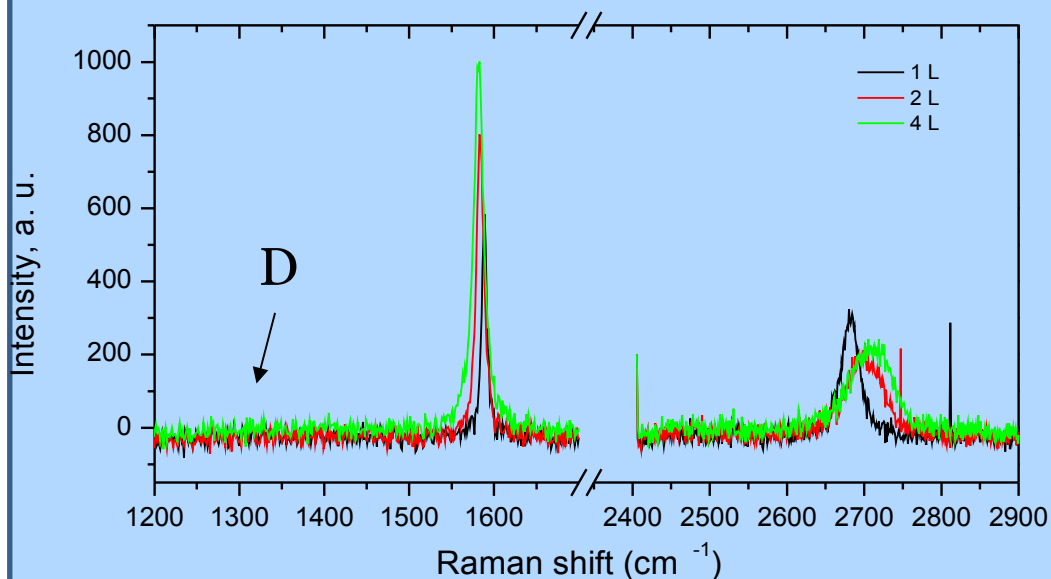
STM and Raman study of graphene samples exposed to high energy protons

STM Imaging

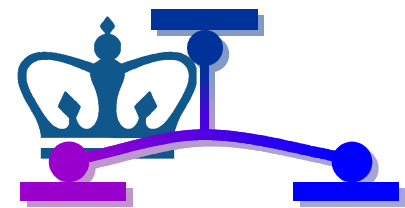


STM imaging of the samples exposed to high energy protons shows no atomic scale defects

Raman Spectroscopy



- G band is blue-shifted by 10 cm⁻¹, indicating significant chemical doping
- There is no signature of the D “defect” band → no structural damage

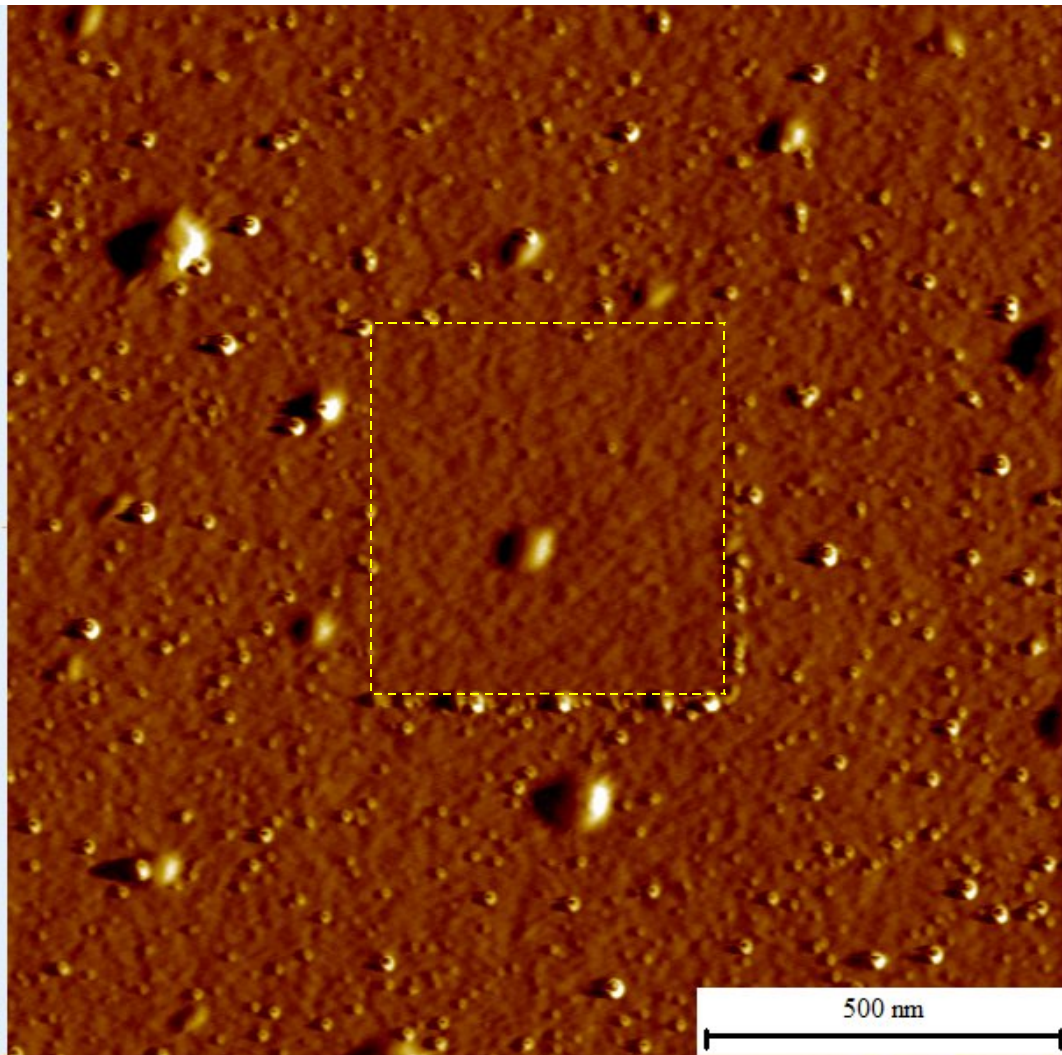


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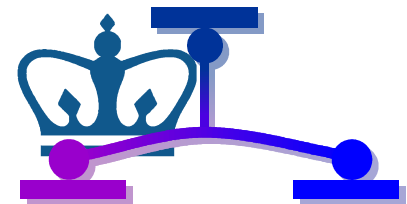
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Mobility of the graphene bubbles



- The center region marked by a dashed square was scanned previously with a lower value of set point in the tapping mode (stronger tip-sample interactions)
- Bubbles can be moved by the AFM tip



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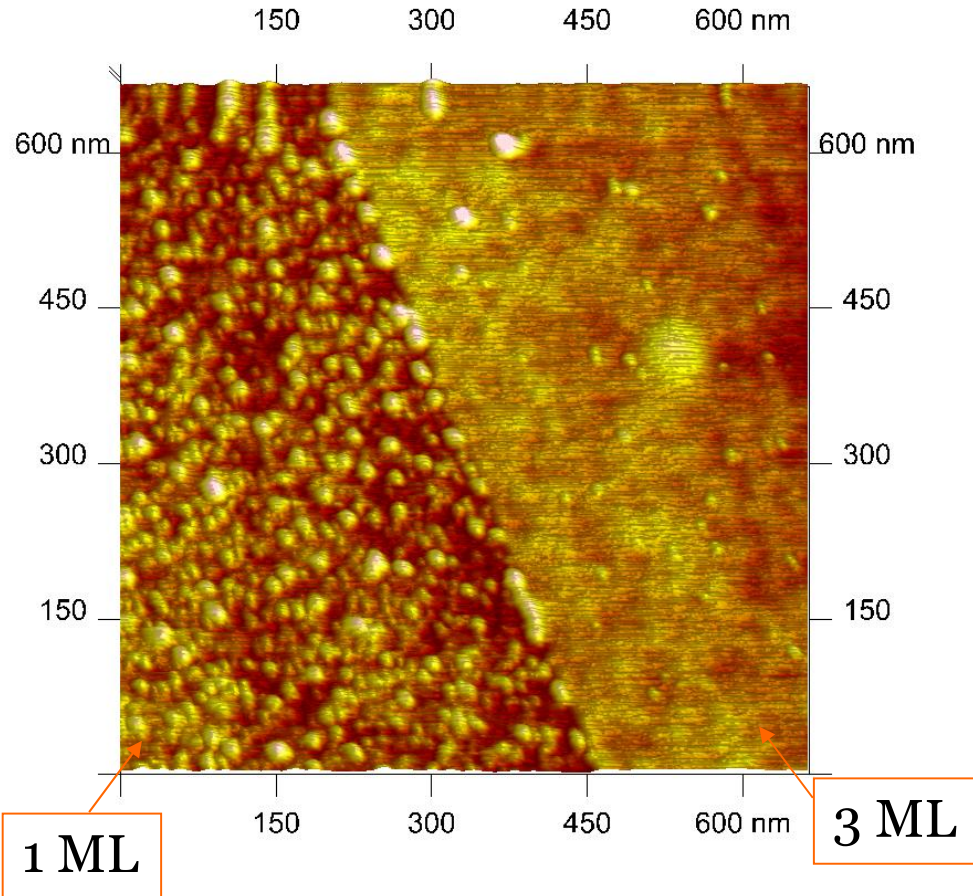
Accelerator Test Facility



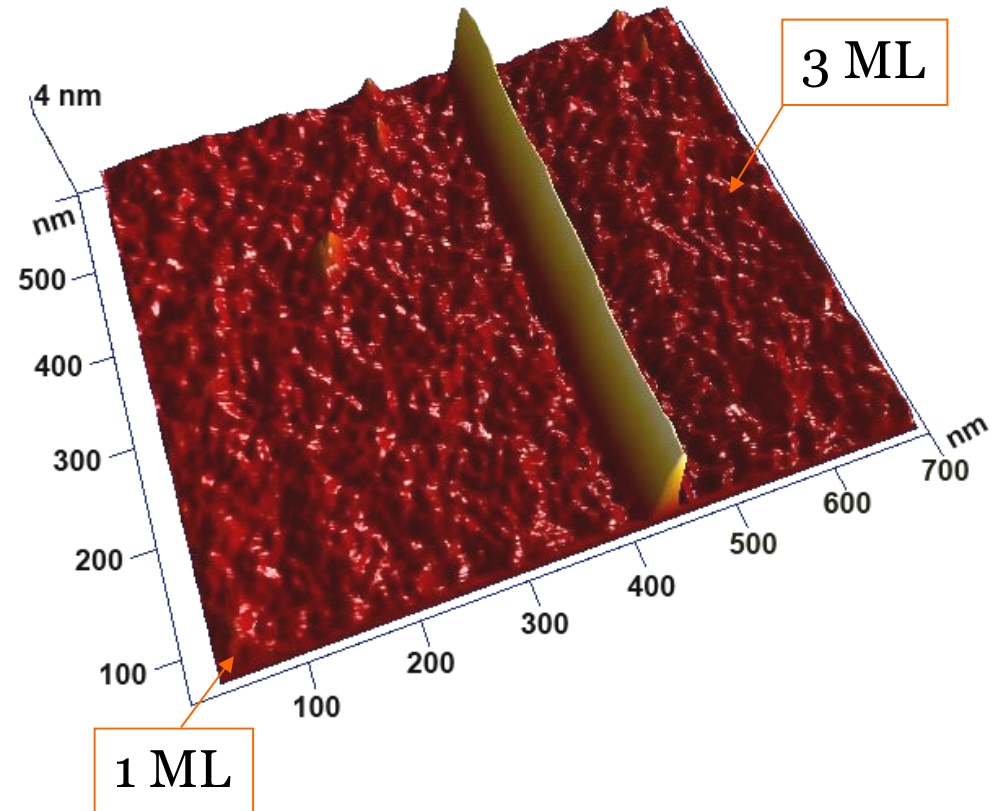
Coalescence of the Bubbles

AFM images of irradiated graphene flakes

Before annealing



After annealing (12 h at 350°C)



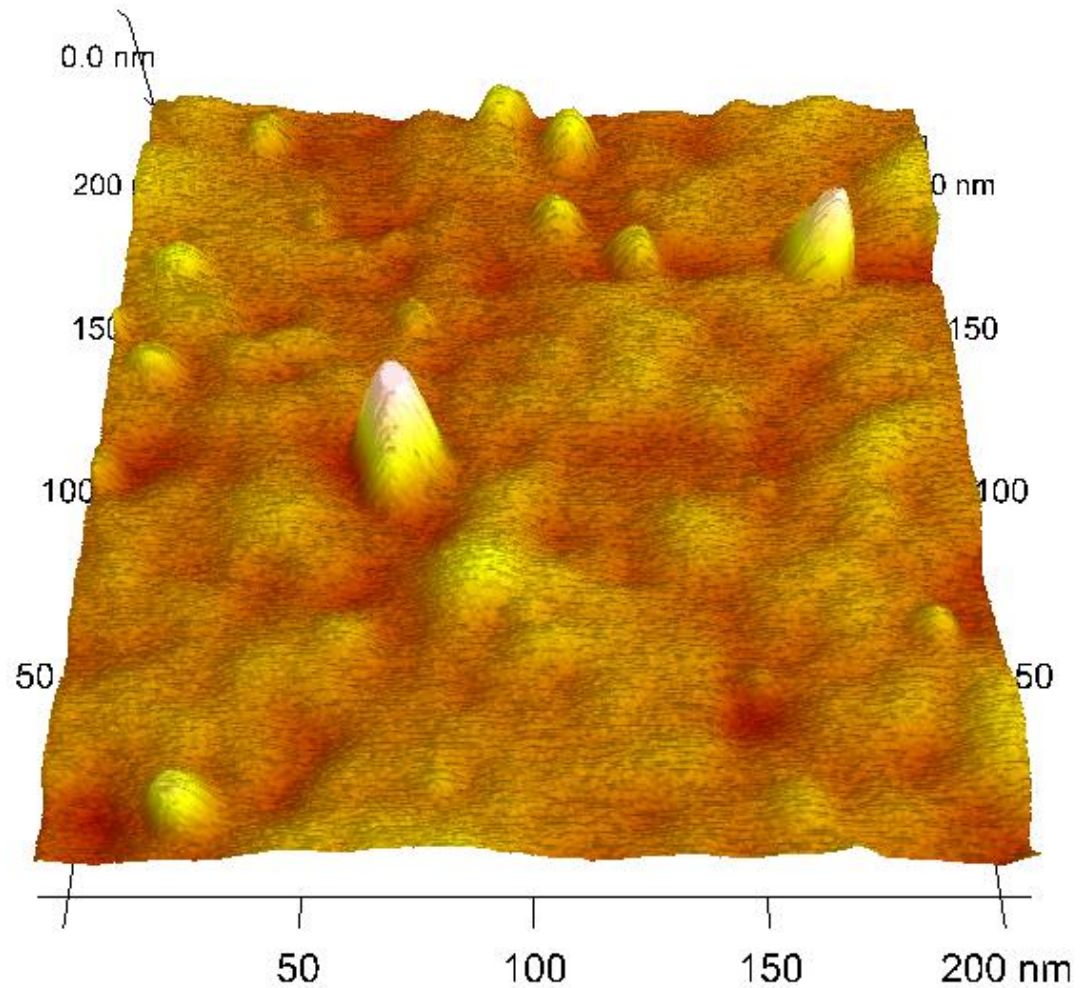
- Annealing causes coalescence of the bubbles
- Transport is possible underneath a graphene film

Summary

Graphene, being only one atom thick, is stable and stiff material.

Graphene membranes can capture mesoscopic volumes of gas.

Graphene acts as an impermeable membrane



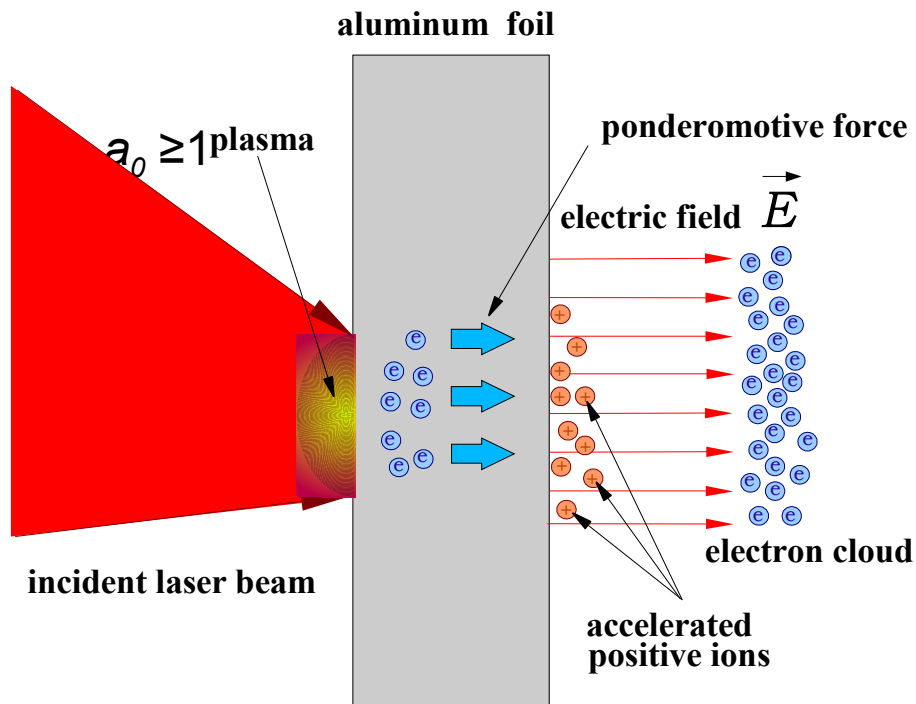
Observation of Graphene Bubbles and Effective Mass Transport under Graphene Films

E. Stolyarova, D. Stolyarov, K. Bolotin, S. Ryu, L. Liu, K. T. Rim, M. Klima, M. Hybertsen, I. Pogorelsky, I. Pavlishin, K. Kutsche, J. Hone, P. Kim, H. L. Stormer, V. Yakimenko, and G. Flynn

Nano Lett., 2009, 9 (1), 332-337 • DOI: 10.1021/nl803087x • Publication Date (Web): 23 December 2008

Advantages of laser-driven ion source for applications in nanotechnology

Target Normal Sheath Acceleration



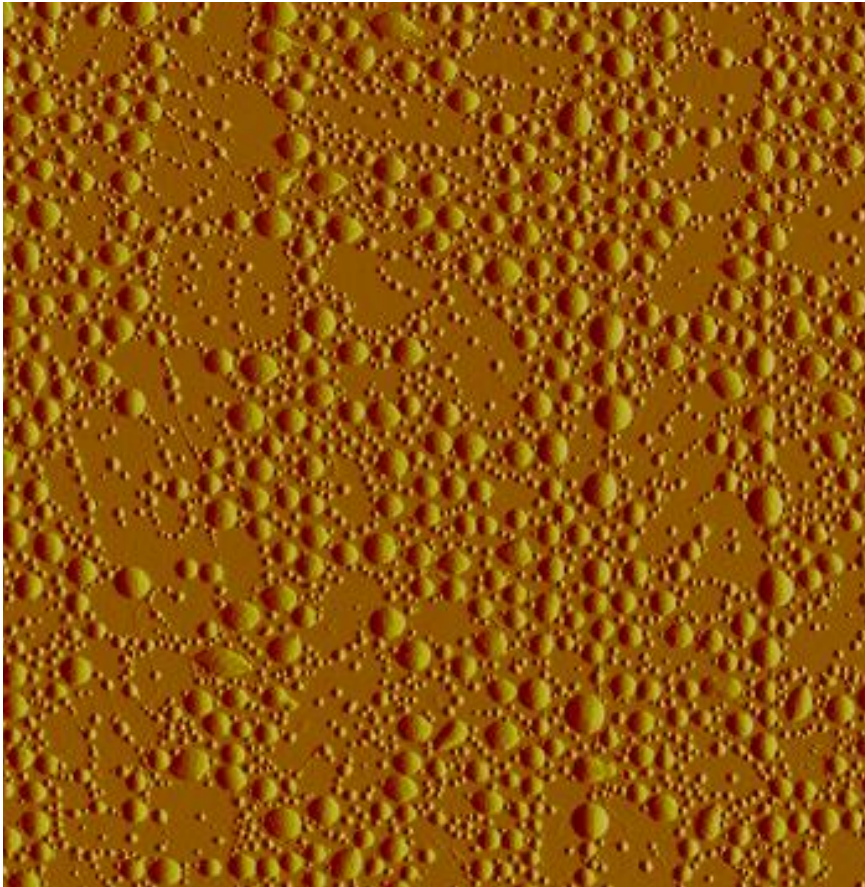
- Material modification under extreme conditions (New physics and chemistry)
- Reimaging/ion writing
- 3D lithography

Compact and inexpensive source of high-energy ions.

Easy switching between different ions by changing the target material.

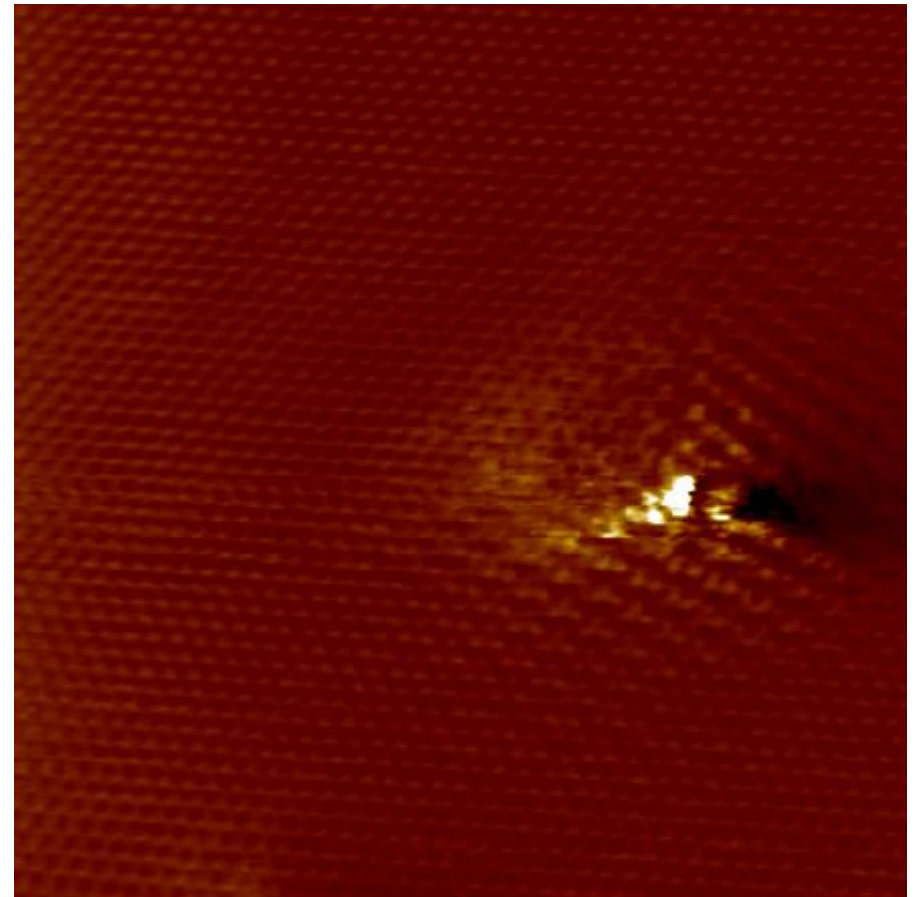
Material modification under extreme conditions

Protons



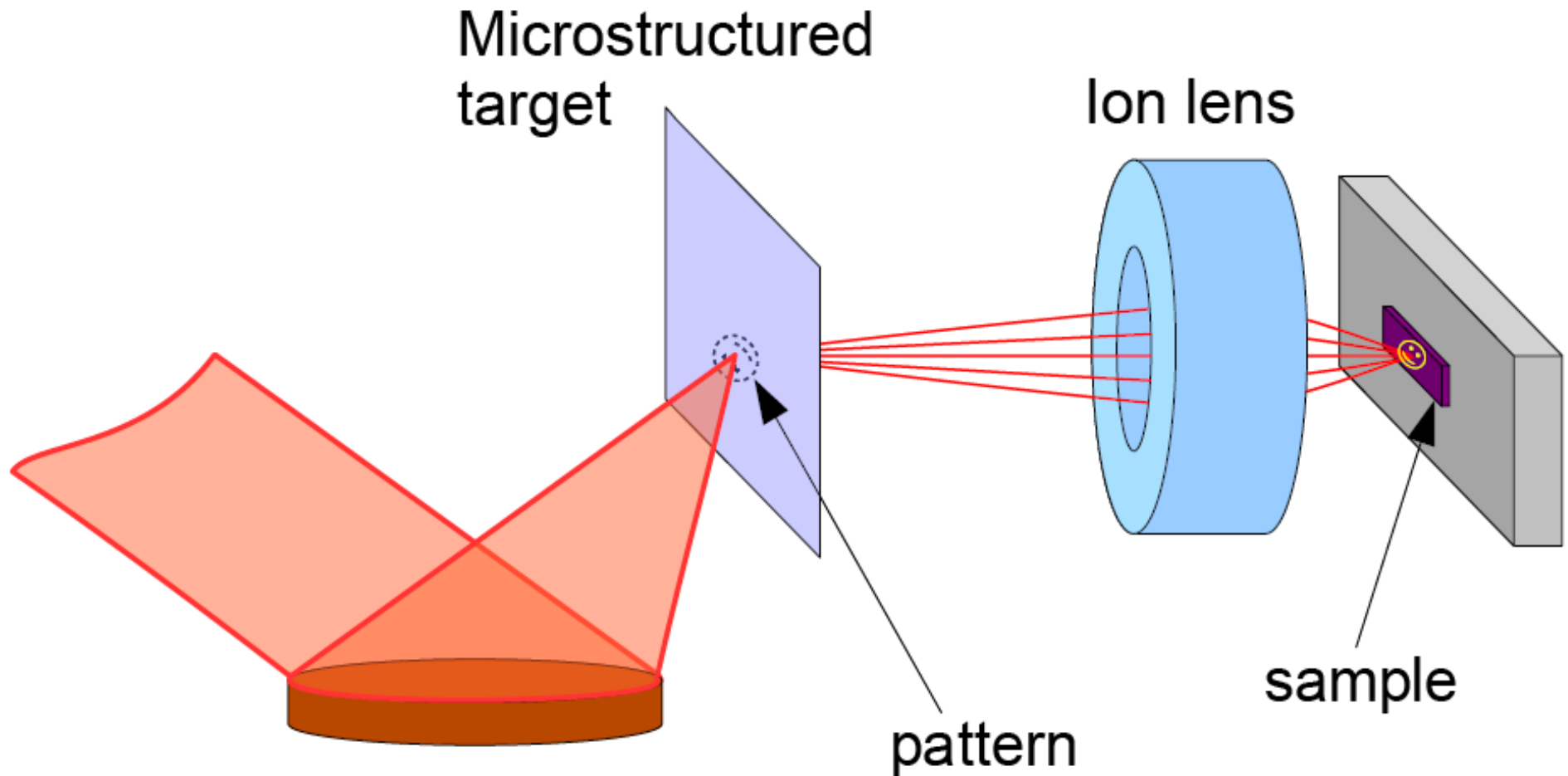
- Ultrafast heating
- Irradiation with pulsed beams

Ions

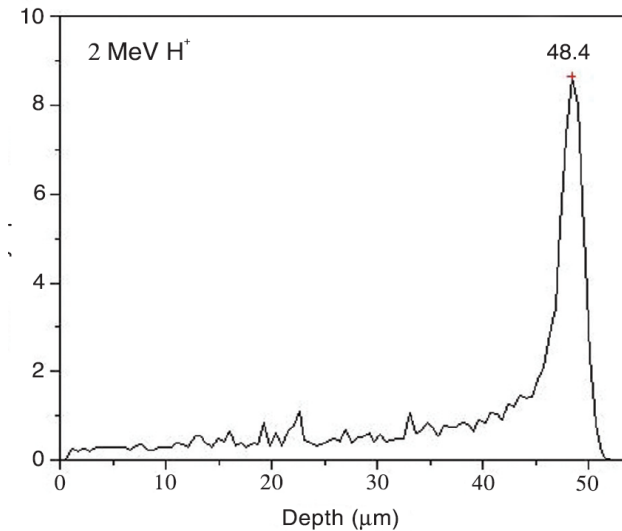
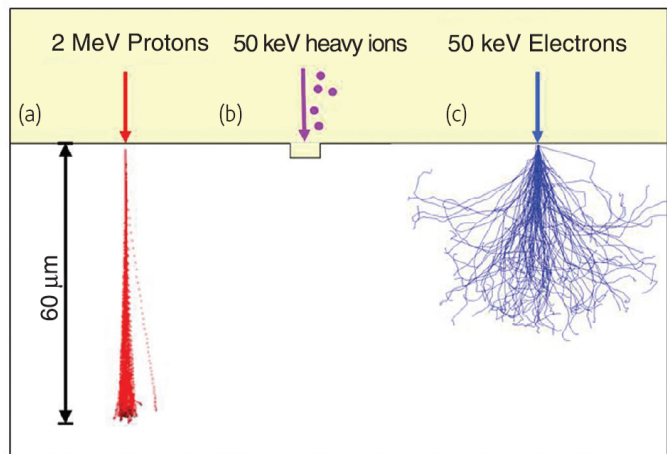


- Defect generation
- Chemical modification of irradiated areas
- Local doping

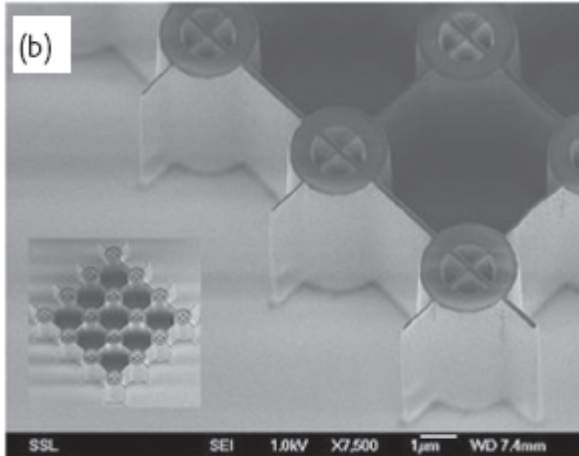
Reimaging target structure



3D proton-beam lithography

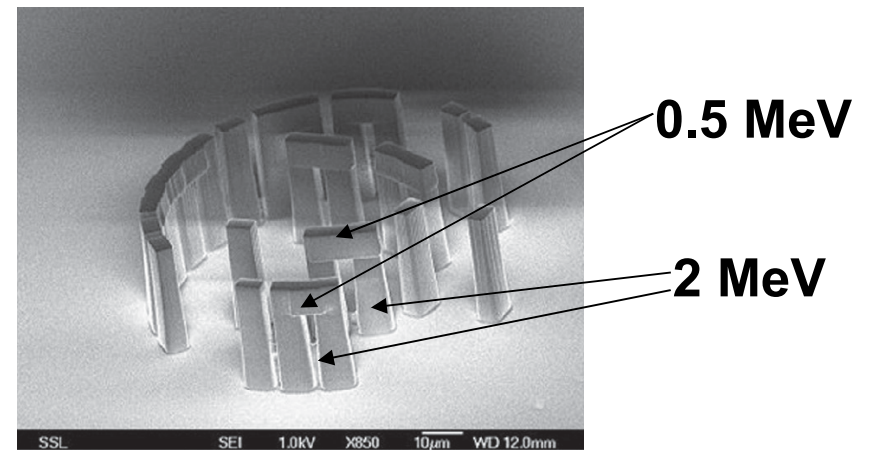


High aspect ratio structures:



p-beam writing in SU-8 negative resist showing 60 nm wall structures that are 10 μm deep

True 3D structures:



Microsized copy of Stonehenge in the UK fabricated using p-beam writing in SU8 resist.

- Prof. George Flynn, Dr. Kwang Rim, Dr. Daejin Eom, Dr. Li Liu (Columbia)
- Prof. Philip Kim, Dr. Kirill Bolotin, Melinda Han, Meninder
- Prof. Horst Stormer, Dr. Etienne De Poortere (Intel), Dr. Erik Henriksen (Caltech)
- Prof. Hone, Martin Klima,
- Prof. Louis Brus, Dr. Sunmin Ryu (Columbia), Prof. Tony Heinz, Dr. Janina Maultzsch
- Dr. Mark S. Hybertsen (CFN, BNL)
- Dr. D. Stolyarov, Dr. I. Pogorelsky, Dr. I. Pavlishin, K. Kusche, Dr. V. Yakimenko (ATF, BNL)



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Accelerator Test Facility



Center for Functional Nanomaterials